IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

te the Application of:

Tamihide YASUMOTO

Group Art Unit: 2813

Serial No.: **09/995,575**

Examiner: KIELIN, Erik J.

Filed: November 29, 2001

Confirmation No.: 1497

For:

SEMICONDUCTOR DEVICE MANUFACTURING METHOD USING METAL SILICIDE REACTION AFTER ION IMPLANTATION IN SILICON WIRING

Attorney Docket No.: 011317 Customer Number: 38834

SUBMISSION UNDER 37 C.F.R. §1.114

Mail Stop RCE Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

February 9, 2004

Sir:

This Submission is being filed concurrently with a Request for Continued Examination pursuant to 37 C.F.R. §1.114. Please amend the application as follows.

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims are reflected in the list of claims which begins on page 3 of this paper.

Amendments to the Drawings begin on page 7 of this paper and include both an attached replacement sheet and an annotated sheet showing changes.

Remarks/Arguments begin on page 8 of this paper.